

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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| In Re Application of: |) | |
| |) | |
| Song et al. |) | Group Art Unit: 1752 |
| |) | |
| Serial No.:10/720,966 |) | Examiner: John S. Y. Chu |
| |) | |
| Filed: November 24, 2003 |) | Confirmation No.: 5221 |
| |) | |
| For: PHOTORESIST COMPOSITION |) | TKHR Docket: 250913-1030 |
| AND METHOD PATTERN |) | Top-Team: 0424-8857US |
| FORMING USING THE SAME |) | |

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed June 26, 2007 has been carefully considered. In response thereto, Applicants hereby submit following amendments and remarks. Reconsideration and allowance of the application and presently pending claims, as amended, are respectfully requested.